



U.S. PATENT DOCUMENTS						
F	0	Document Number	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where Relevant	
Examiner Initials*	Cite No.1	Number-Kind Code ² (if known)		Applicant of Cited Document	Passages or Relevant Figures Appear	
7V.S./	1.	US-5,946,214	08-31-1999	Heavlin et al.		
ŊŞĮ	2.	US-6,449,749	09-10-2002	Stine		
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		Country Code ³ -Number ⁴ -Kind Code ⁵ (if known)				T ⁶
7V.S./	5.	WO-05036422	04-21-2005	PDF Solutions, Inc.		

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